

XP-002213664

AN - 2000-056963 [05]

AP - JP19980132659 19980427

CPY - KONS

DC - G06 P83 P84

FS - CPI;GMPI

IC - G03C1/035 ; G03C5/26 ; G03C7/413 ; G03D5/00

MC - G06-F01 G06-G10

PA - (KONS ) KONICA CORP

PN - JP11305412 A 19991105 DW200005 G03D5/00 034pp

PR - JP19980132659 19980427

XA - C2000-015636

XIC - G03C-001/035 ; G03C-005/26 ; G03C-007/413 ; G03D-005/00

XP - N2000-044415

AB - JP11305412 NOVELTY - The viscosity and surface tension of a liquid used for processing silver halide photosensitive material, are 1.5-10 cps at 25 deg. C and 15-50 dynes/cm, respectively. The liquid is supplied by a liquid supply unit to the emulsion surface of the material, by applying pressure or a gaseous phase.

- USE - The method is used for processing silver halide photosensitive material.

- ADVANTAGE - The liquid used for processing silver halide photosensitive material has excellent shelf-life and stability at the time of continuous operation. The processing method enables maximum color development concentration in the photosensitive material.

- (Dwg.0/5)

IW - PROCESS SILVER HALIDE PHOTOSENSITISER MATERIAL LIQUID PREDETERMINED VISCOSITY SURFACE TENSION

IKW - PROCESS SILVER HALIDE PHOTOSENSITISER MATERIAL LIQUID PREDETERMINED VISCOSITY SURFACE TENSION

NC - 001

OPD - 1998-04-27

ORD - 1999-11-05

PAW - (KONS ) KONICA CORP

TI - Processing of silver halide photosensitive material - involves using a liquid having predetermined viscosity and surface tension